IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Shen, et al.

Group Art Unit: 1746

Serial No: 09/507.629

Examiner: Unknown

Confirmation No: 7912

Atty. Docket No.

001945 USA P03/ETCH/SILICON/JB

Filed: February 18,2000

SELF-CLEANING PROCESS

FOR ETCHING SILICON-

CONTAINING MATERIAL

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

FEB 4 2002

TC 1700

Box Non-Fee Amendment Commissioner for Patents Washington, D.C. 20231

Dear Sir:

For:

Attached hereto is a PTO-1449 form listing documents believed relevant to the subject application. It is respectfully requested that these documents be considered by the Examiner and an initialed copy of the form be returned to the undersigned.

Under 37 C.F.R. § 1.97(b) (3), an Information Disclosure Statement shall be considered by the Office if filed before the mailing date of the first office action.

It is believed that no fee is due for the filing of this Supplemental Information Disclosure Statement. If any fee is due, the Commissioner is hereby authorized to charge payment of any such fees, or credit any overpayment, to Deposit Account No. 10-0258.

I hereby cert fy that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to
Box Non-Fee Amendment
By

S/N: 09/507.629 Page 2 of 2

Also, if any Petition is required for the filing of this Supplemental Information Disclosure Statement, such Petition is requested herein.

A copy of each document is enclosed.

Some of the documents may have markings thereon. No significance is meant to be attached to the markings.

With regard to any translations which may be provided herewith, the undersigned does not know how and who made the translations. Therefore, no representation is being made as to the accuracy of any translation.

These documents are not necessarily analogous.

Respectfully submitted

JANAH & ASSOCIATES
A PROFESSIONAL CORPORATION

Date: December 7, 2001

sy: ____

Ashok K. Janah

Reg. No. 37,487

Please direct all telephone calls:

Ashok K. Janah (415)538-1555

Please continue to send all correspondence to:

Applied Materials, Inc. Patent Department P.O. Box 450A

THE PROPERTY OF THE PROPERTY OF OFFI

Encl

FORM PTO 1449 U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE								DOCKET NO -001945 USA POSÆTCH/SILICONJB				APPLICATION NO: 09 507,629		
INFORMATION DISCLOSURE STATEMENT								APPLICANT. Shen, et al.						
IN AN APPLICATION (Use several sheets it necessary								FILING DA	GROUP ART UNIT					
							U	.S. PATEN	T DOCUMENTS					
EXAMINER INTITAL	DOCUMENT NUMBER							DATE	NAME.	CLASS	SUBCLAS FILING DATE IF APPROPRIA			
	5	2	1	ij	4	8	5	06/15/93	Wang, et al.					
	5	2	5	J.	ij	2	3	11/09/93	Hori, et al.					
	5	;	5_	4_	4	1.	6	10/11/94	Okudaira, et al.					
	ļ				-	 	 	-						
		ļ	-	<u> </u>	-			ļ				-		
		-			-	+-					BECK			
		}	-	-	+	-					FEB 4	160		
	-	ļ	+	-	+-	+		 			70	002		
		1	+	+	-	+					C 1701			
		-	-		+	1								
	<u> </u>				!		FOI	REIGN PA	TENT DOCUMENT	ГS				
	DOCUMENT NUMBER								COUNTRY	CLASS	SUBCLAS	TRANSLATION		
					1		-				8	YES	NO	
	ļ	_	-	-	<u> </u>		-							
	-	-	 	+-	+-	+	-	-					_	
	-	+	-	+	-	+	+		1					
	+	+	+	+	+	+-	+							
							ATTRICE.	C (In de I')	a Author Title Date	Partinant P	lages etc.)			
	1		<u>O1</u>	LHE	K DO	CUN	IEN I	s (Incluain	g Author, Title, Date	, 1 eranem 1	uges, eic.			
	-	•												
	+													
EXAMINER										DATEC	DATE CONSIDERED			
		ial if r	eferen	ce con	sidere	d, who	ther or	not citation is	in conformance with M	IPEP 609. Draw	line through c	itation if not	ın	